



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Pei-Yang Yan

Serial No.: 10/631,171

Filed: July 31, 2003

For: Multilayer Reflective Extreme
Ultraviolet Lithography Mask Blanks

§
§
§
§
§
§
§
§
§

Art Unit: 1756

Examiner: Stephen D. Rosasco

Docket: ITL.0952US
P15976

Assignee: Intel Corporation

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO FINAL REJECTION

Sir:

In response to the final rejection mailed August 12, 2005, reconsideration is requested in view of the attached Terminal Disclaimer.

Date of Deposit: August 30, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden
Cynthia L. Hayden